

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L8	289	(205/662.ccls. 204/229.4.ccls.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/27 15:34
S1	2	"5807165".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:21
S2	2	"20040060814".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:22
S3	3	"6706158".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:31
S4	55	intel.as. and ("204" "205").clas.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:24
S5	60	((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3)) and @ad<"20010901"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 10:37

S6	11	((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)) and @ad<"20010901" and ((voltage potential) with (control controll\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:09
S7	1971	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)) and @ad<"20010901" and ((voltage potential) with (control controll\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:11
S8	0	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)) and @ad<"20010901" and (((voltage potential) with (control controll\$3)) same (temperature and (flow adj rate) and (speed near2 (rotation rotat\$3))))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:14
S9	198	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)) and @ad<"20010901" and (((voltage potential) with (control controll\$3)) same (temperature))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:15
S10	22	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)).clm. and @ad<"20010901" and (((voltage potential) with (control controll\$3)) same (temperature))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:20

S11	6	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)).clm. and @ad<"20010901" and (((voltage potential) with (control controll\$3)) same (flow adj rate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:25
S12	68	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)).clm. and @ad<"20010901" and (((process process\$3 polish polish\$3) with (control controll\$3)) same (flow adj rate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:31
S13	62	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)).clm. and @ad<"20010901" and (((process process\$3 polish polish\$3) with (control controll\$3)) same (speed near2 (rotation rotat\$3)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:35
S14	10	((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz\$3 planarizat\$3)).clm. and @ad<"20010901" and (((process process\$3 polish polish\$3) with (control controll\$3)) same PID)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/17 11:35
S15	4	("6176992" "6402925" "6413403" "6464855"). PN.	US-PGPUB; USPAT; USOCR	OR	ON	2009/01/26 17:14

S16	4313	(((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3))) electroprocess electroprocess\$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process \$3))) and @ad<"20010901" and ((voltage potential current) with (control controll\$3 individual individually separate separate\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 17:37
S17	2067	(((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3))) electroprocess electroprocess\$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process \$3))) and @ad<"20010901" and ((voltage potential current) with (control controll\$3 individual individually separate separate\$3)) and (wafer workpiece substrate microelectronic)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 17:39

S18	469	(((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3))) ((electroprocess electroprocess\$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process \$3))) with (wafer workpiece substrate microelectronic))) and @ad<"20010901" and ((voltage potential current) with (control controll\$3 individual individually separate separate\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 17:40
S19	1210	(((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3))) ((electroprocess electroprocess\$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process \$3))) with (wafer workpiece substrate microelectronic))) and (((voltage potential current anode cathode electrode) with (individual individually separate separate\$3 segment segment\$3)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 18:05

S20	877	(((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3))) ((electroprocess electroprocess\$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process \$3))) with (wafer workpiece substrate microelectronic))) and (((voltage potential current anode cathode) with (individual individually separate separate\$3 segment segment\$3)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 18:05
S21	664	S20 not S18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/26 18:06
S22	438	(((electrochemical electrochemically electrolytic electrolytically) adj (mechanical mechanically) adj (polish polish\$3 planarize planariz \$3 planarizat\$3))) ((electroprocess electroprocess\$3 ((electrochemical electrochemically electrolytic electrolytically) near2 (process process \$3))) with (wafer workpiece substrate microelectronic))) and (((voltage potential current anode cathode) with (individual individually separate separate\$3 segment segment\$3)))	US-PGPUB	OR	ON	2009/01/27 10:41

1/27/2009 3:57:28 PM

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